



Form 1449 (Modified)

**Information Disclosure
Statement By Applicant**

(Use Several Sheets if Necessary)

Atty Docket No.
NOVLP089/ NVLS-2887

Application No.:
10/800,377

Applicant:
Cho et al.

Filing Date
March 11, 2004

Group
2822

U.S. Patent Documents

Examiner Initial	No.	Patent No.	Date	Patentee	Class	Sub-class	Filing Date
KP ↓	A1	6,573,030 B1	06.03.03	Fairbairn et al.			
	A2	2004/0096586 A1	05.2004	Schulberg et al.			
	A3	2003/0198895 A1	10.2003	Toma et al.			
	A4	6,846,380 B2	01.2005	Dickinson et al.			
	A5	6,867,086 B1	03.2005	Chen et al.			
	A6	6,903,004	06.2005	Spencer et al.			
	A7	6,232,658 B1	05.2001	Catabay et al.			
	A8	6,171,661	01.2001	Zheng et al.			
	A9	2002/0016085	02.2002	Huang et al.			
	A10	6,455,417	09.2002	Bao et al.			
	A11	7,018,918	03.2006	Kloster et al.			
	A12	6,849,549	02.2005	Chiou et al.			

Other Documents

Examiner Initial	No.	Author, Title, Date, Place (e.g. Journal) of Publication
KP ↓	C1	Subramonium et al., "Pulsed PECVD Method for Modulating Hydrogen Content in Hard Mask", U.S. Application No. 11/318,269, filed December 23, 2005 (Atty Dkt: NOVLP144/NVLS-3102)
	C2	U.S. Office Action mailed February 28, 2006, from U.S Application No. 10/404,693 [Atty Dkt No. NOVLP064/NVLS-794].
	C3	U.S. Office Action mailed May 31, 2006, from U.S Application No. 10/941,502 [Atty Dkt No. NOVLP107/NVLS-2932].
	C4	U.S. Office Action mailed May 30, 2006, from U.S Application No. 10/785,235 [Atty Dkt No. NOVLP085/NVLS-2875].
	C5	U.S. Office Action mailed May 31, 2006, from U.S Application No. 10/849,568 [Atty Dkt No. NOVLP083/NVLS-2867].
	C6	U.S. Office Action mailed May 2, 2006, from U.S Application No. 11/050,621 [Atty Dkt No. NOVLP100/NVLS-2956].
	C7	U.S. Office Action mailed June 15, 2006, from U.S Application No. 10/800,409 [Atty Dkt No. NOVLP098/NVLS-2907].
	C8	Kelman et al., "Method for Reducing Stress in Porous Dielectric Films", U.S. Application No. 11/369,311, filed March 6, 2006 (Atty Dkt: NOVLP154/NVLS-3121)
	C9	U.S. Office Action mailed May 2, 2006, from U.S Application No. 10/295,965.
	C10	U.S. Office Action mailed August 9, 2005, from U.S Application No. 10/295,965.
Examiner /Kevin Picardat/		Date Considered 10/02/2006

Examiner: Initial citation considered. Draw line through citation if not in conformance and not considered.
Include copy of this form with next communication to applicant.